



Influence of post deposition annealing on thermoelectric properties of In_2Se_3 thin films

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ARTICLE INFO

Keywords:

Post deposition annealing
Thermal conductivity
3 ω -method
 In_2Se_3
Thin films

ABSTRACT

In the present work, thermoelectric properties of thin films of In_2Se_3 are explored, with its low thermal conductivity and high electrical conductivity simultaneously, reported for the bulk ceramics and improved results for the doped systems for both cation and anion sites. Here, In_2Se_3 thin films are grown using thermal evaporation technique and the effect of post deposition annealing on the thermoelectric properties of In_2Se_3 thin films are studied. XRD, Raman and UV-visible spectroscopy show that the as grown film corresponds to α - In_2Se_3 phase which gets transformed to the γ -phase of In_2Se_3 upon annealing at 300 °C. The Hall measurements indicate that the films exhibit a high electron mobility and electrical conductivity. 3 ω -method is employed for the thermal conductivity measurements of the as grown thin films of In_2Se_3 which is found to be 0.75 $\text{W m}^{-1}\text{K}^{-1}$. Thermoelectric properties including the power factor and the ZT values are found to reach as high as 12.04 $\mu\text{W m}^{-1}\text{K}^{-2}$ and 4.9×10^{-3} respectively for the films post annealed at 300 °C. Our findings pave the simple way of energy generation based on the waste heat dissipation with the device size of few nm for the next generation device applications.

1. Introduction

A global demand of energy is increasing every day and the sources of energy are still majorly dependent upon the fossil fuels which lead to global warming and are also decaying continuously. This makes it necessary to find out alternate energy sources or harvest the waste energy. Thermoelectric effect is one of the important phenomena in which the temperature difference can be directly converted into electrical energy. It serves an efficient method to harvest energy from the waste heat dissipated from industries, heavy automotive vehicles and the heat coming from the sun [1]. The choice of a good thermoelectric material depends on its conversion efficiency of least spatial temperature gradient. The efficiency of a thermoelectric material is defined as [2]:

$$\eta = \frac{\sqrt{1+ZT}}{\sqrt{1+ZT} + \frac{T_c}{T_h}} \times \frac{\Delta T}{T_h} \quad (1)$$

where, T_c and T_h are the temperature at the cold and hot ends, ΔT is the difference between the two temperatures ($T_c - T_h$). The relation between the figure of merit (ZT), electrical and thermal conductivity is as follows:

$$ZT = \frac{\sigma S^2 T}{\kappa} \quad (2)$$

where, σ and κ are the electrical conductivity and the thermal conductivity, respectively. The Seebeck coefficient (S) is defined as the change in the generated voltage with respect to the change in temperature between the two ends, where one end is kept at a fixed temperature T [1]. There are many materials like oxides (Al:ZnO , Zn_xO_y) [3,4], silicides (SrSi_2 , CrSi_2) [5,6], stannides (Mg_2Sn) [7], Heusler alloys (Fe_2VAl) [8,9], skutterudites (CoSb_3) [10] etc. explored as the thermoelectric material, but they exhibit low thermoelectric performance and rapidly lose their useful properties because of oxidation [11]. The metal chalcogenides explored so far for the conventional thermoelectric applications are PbTe , Bi_2Te_3 , Sb_2Te_3 , SnTe , GeTe etc., where Bi_2Te_3 is being one of

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